Claim Amendments

Please amend claims 1, 3, 7-9, 11, 15, 17-19 as follows:

Listing of Claims

1. (currently amended) An electrolyte <u>bath comprising a</u>

<u>suspension layer for forming a wetting layer on a substrate</u> for copper electroplating, comprising:

an electrolyte solution; and

a composition comprising an organic acid and a nonionic polymer mixed with said organic acid provided in said electrolyte solution;

wherein said composition forms a separated suspension layer within said electrolyte solution.

- 2. (original) The electrolyte of claim 1 wherein said organic acid is citric acid or acetic acid.
- 3. (currently amended) The electrolyte of claim 1 wherein said non-ionic polymer is an alcohol, an amine or alkylphenol alkoxylate.
- 4. (original) The electrolyte of claim 1 wherein said composition is present in said electrolyte solution in a concentration of

about 5 % by weight.

- 5. (original) The electrolyte of claim 1 wherein said non-ionic polymer has a molecular weight of less than 1,000.
- 6. (original) The electrolyte of claim 5 wherein said organic acid is citric acid or acetic acid.
- 7. (currently amended) The electrolyte of claim 1 wherein said organic acid is present in said composition in a wt.% of about 10, and wherein said non-ionic polymer is present in said composition in a wt.% of about 5.
- 8. (currently amended) The electrolyte of claim 7 wherein said organic acid is citric acid or acetic acid and said non-ionic polymer is an alcohol, an amine or alkylphenol alkoxylate.
- 9. (currently amended) An electrolyte <u>bath comprising a</u>

 <u>suspension layer for forming a wetting layer on substrate prior</u>

 <u>to [[for]] copper electroplating said substrate layer within said</u>
 electrolyte, comprising:

an electrolyte solution; and

a composition comprising an organic acid and a nonionic polymer mixed with said organic acid provided in;

wherein said composition forms a separated suspension layer within said electrolyte solution said suspension layer for forming a wetting layer on a substrate as said substrate is passed through said suspension layer.

- 10. (original) The electrolyte of claim 9 wherein said organic acid is citric acid or acetic acid.
- 11. (currently amended) The electrolyte of claim 9 wherein said non-ionic polymer is an alcohol, an amine or alkylphenol alkoxylate.
- 12. (original) The electrolyte of claim 11 wherein said composition is present in said electrolyte solution in a concentration of about 5% by weight.
- 13. (original) The electrolyte of claim 9 wherein said organic acid is present in said composition in a wt.% of about 10, and wherein said non-ionic polymer is present in said composition in

a wt.% of about 5.

- 14. (original) The electrolyte of claim 13 wherein said organic acid is citric acid or acetic acid.
- 15. (currently amended) The electrolyte of claim 13 wherein said non-ionic polymer is an alcohol, an amine or alkylphenol alkoxylate.
- 16. (original) The electrolyte of claim 15 wherein said organic acid is citric acid or acetic acid.
- 17. (currently amended) A method for electroplating a metal onto a surface in an electroplating electrolyte solution, comprising the steps of:

providing a composition mixture comprising an organic acid and a non-ionic polymer;

forming a suspension layer of said composition mixture within said electrolyte solution;

forming a wetting layer on said surface by passing said

surface through said suspension layer and into said <u>electrolyte</u> solution; and

electroplating said metal onto said surface.

- 18. (currently amended) The method of claim 17 wherein said organic acid is citric acid or acetic acid and said non-ionic polymer is an alcohol, an amine or alkylphenol alkoxylate.
- 19. (currently amended) The method of claim 17 wherein said organic acid is present in said composition in a wt.% of about 10, and wherein said non-ionic polymer is present in said composition in a wt.% of about 5.
- 20. (original) The method of claim 17 further comprising a substrate and wherein said surface comprises a metal seed layer deposited on said substrate.

Remar<u>ks</u>

Thorough examination by the Examiner is noted and appreciated.

Applicants have amended the Specification as required by Examiner, and thank Examiner for careful examination.